

Simulation of a Voltage Controlled Resistor Mimicking the Geometry of a MOSFET Device having Graphite Channel

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Outline :

- Introduction
- Geometry of device
- Application COMSOL multiphysics
- Results
- Summary



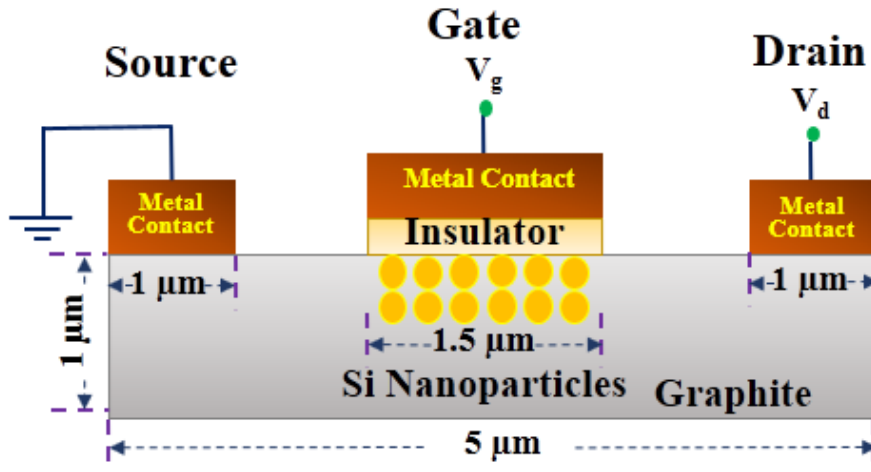


Introduction :

- **Voltage Control Resistor (VCR) :**
A device where the resistance or conductance depends upon external voltage.
- The device has **3 terminals**.
- Geometry is **similar to MOSFET** device.



Geometry of the Device :



- V_g (gate voltage) can be termed as control voltage.
- V_d (drain voltage) can be termed as applied voltage.

Governing Equations :

$$\nabla \cdot (\epsilon_r \nabla V) = q(n - p + N_A^- - N_D^+)$$

Poisson's eqn.

$$\frac{1}{q} \nabla \cdot J_n = -U_n$$

$$\frac{1}{q} \nabla \cdot J_p = U_p$$

Continuity eqns.

$$J_n = (\mu_n \nabla E_c + \frac{qD_{n,th}}{T_I} \nabla T_I) n + \mu_n k_B T_I G(n / N_C) \nabla n$$

Fermi-dirac
carrier statistics

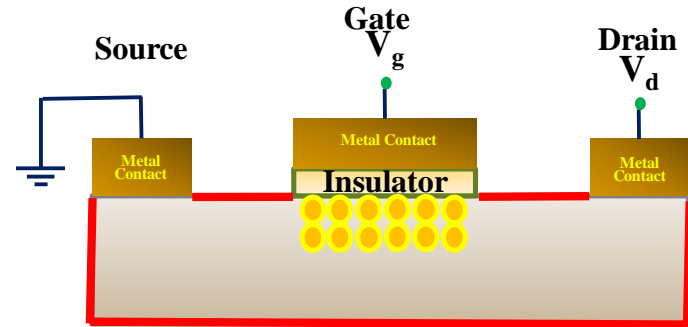
$$J_p = (\mu_p \nabla E_c + \frac{qD_{p,th}}{T_I} \nabla T_I) p + \mu_p k_B T_I G(n / N_V) \nabla p$$





Assumption :

- Insulation at the boundaries.



- Ohmic metal contact.

- All the terminals are voltage terminal.



Application COMSOL Multiphysics :

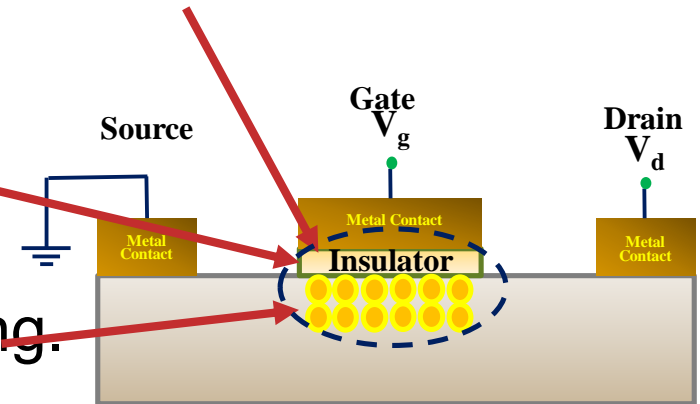
- **Module:** Semiconductor.
- **Method:** Finite volume.
- **Discretization:** Scharfetter - gummel.
- **Carrier Statistics:** Fermi-dirac.
- **Mesh:** Triangular mesh with 29429 domain elements.
- **Study:** Stationary.





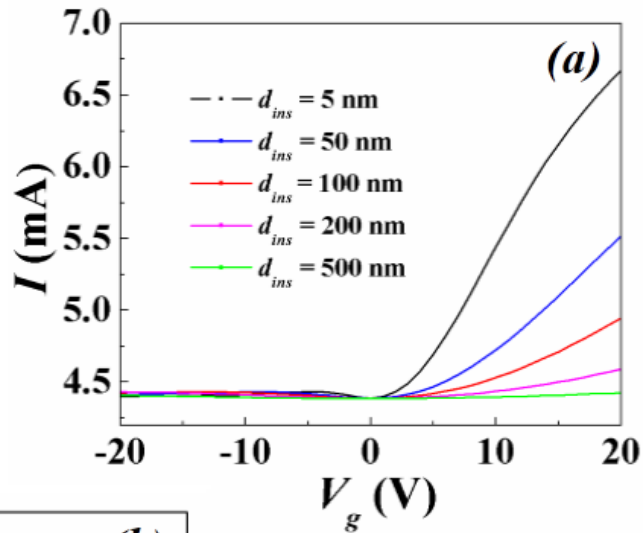
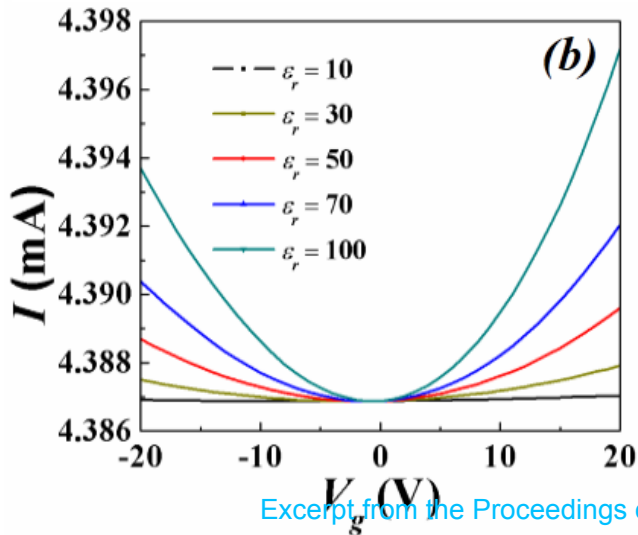
Parameters that Effects Channel Current :

- Dielectric constant of insulator layer (ϵ_r).
- Thickness of insulator (d_{ins}).
- Effect of Si nanoparticle loading.



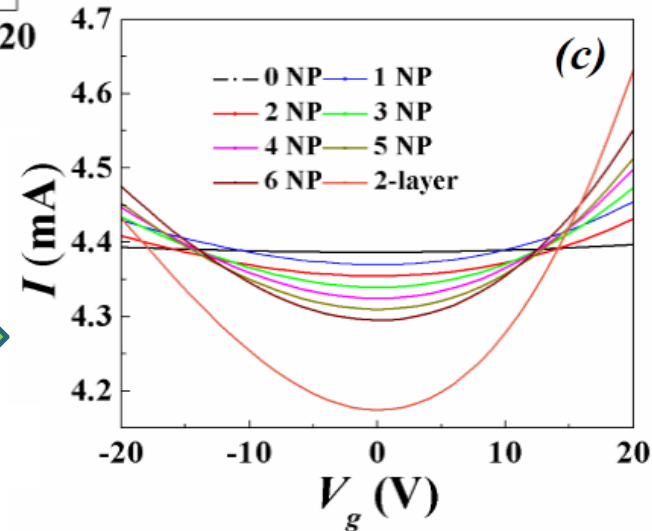
Results :

Effect of dielectric constant of insulator layer



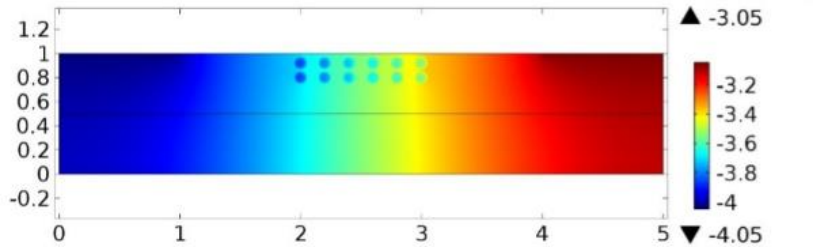
Effect of thickness of insulator layer

Effect of Nanoparticle loading in channel



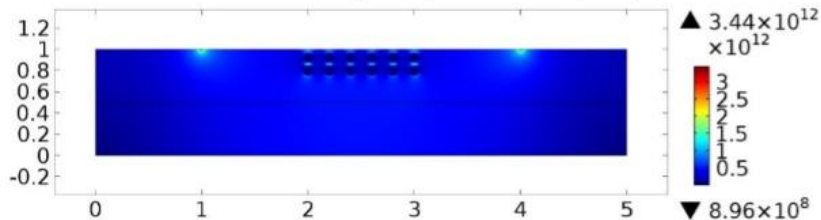
Surface Potential and Current Density :

(a) $V_g=20, V_d=1$ Surface: Electric potential (V)

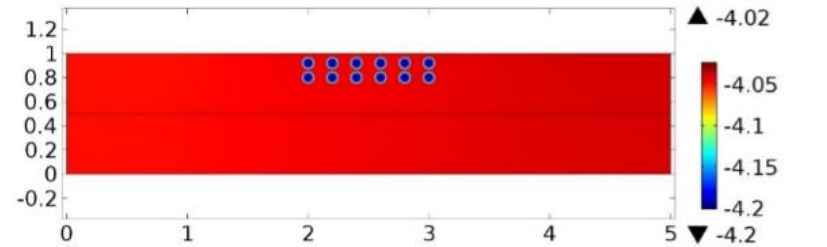


$V_g=20, V_d=1$

Surface: Total current density norm, nodal value (A/m^2)

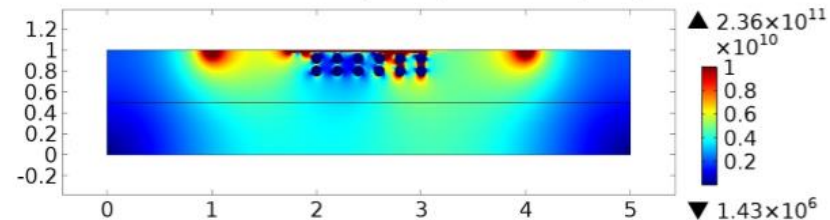


(b) $V_g=20, V_d=0.01$ Surface: Electric potential (V)

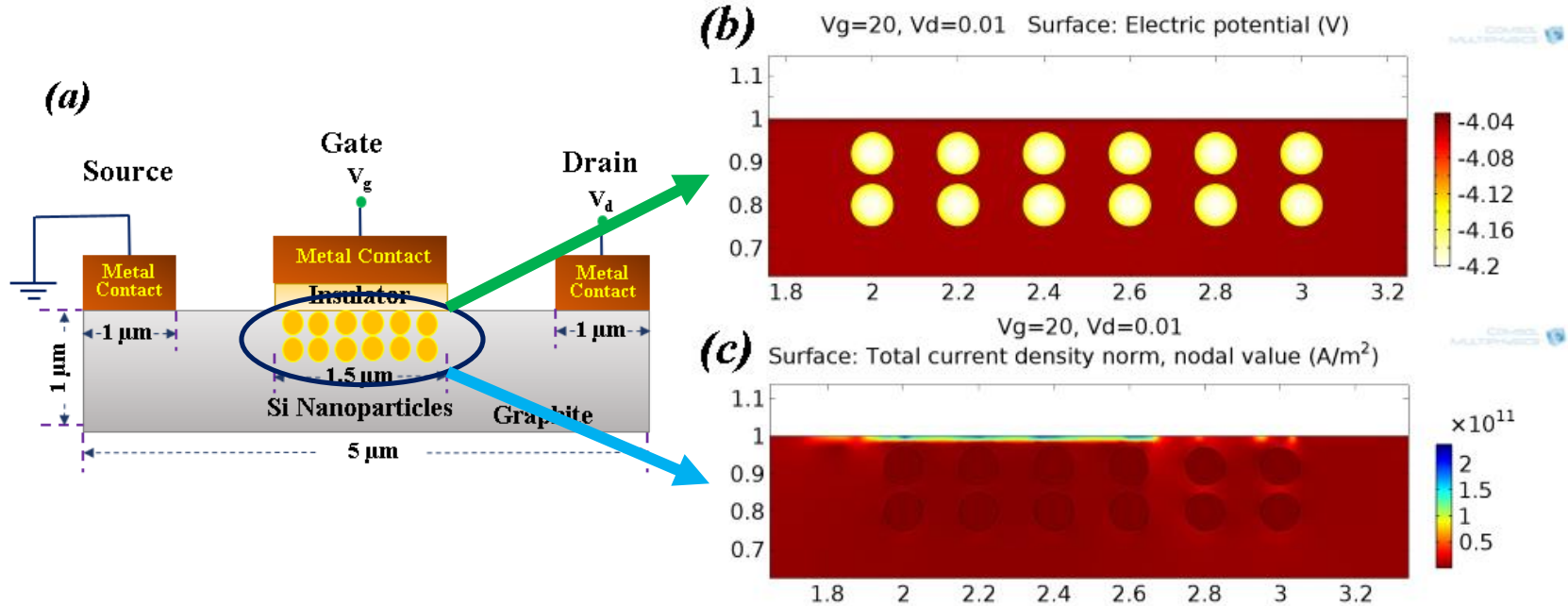


$V_g=20, V_d=0.01$

Surface: Total current density norm, nodal value (A/m^2)



At Channel Region :





Summary :

- Channel is made of graphite.
- Current through the channel depends on the external control voltage (V_g).
- Channel current depends on d_{ins} and Si nanoparticle loading but depends very less on \mathcal{E}_r .





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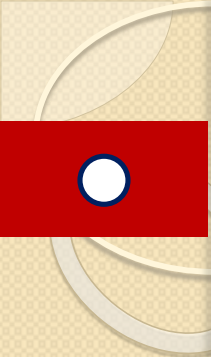




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Thank You

